

ULTRASONIC CLEANING TANK

Priority Claim

The present invention claims priority to United States Provisional Application Serial No.
5 60/444,752 entitled, "ULTRASONIC CLEANING TANK", filed February 4, 2003, and hereby
incorporated by reference in its entirety.

Field of the Invention

The present invention relates generally to an ultrasonic system for precision cleaning of
10 parts. In particular, the invention relates to an ultrasonic cleaning system that includes a cleaning
tank with an internal dispersion plate adapted to promote upward laminar flow within the
cleaning tank for improved part cleaning.

Background of the Invention

15 Precision cleaning and drying systems typically utilize a wide variety of cleaning
solutions including various solvents, detergents, or other aqueous mixtures. These systems
operate to clean and dry various devices or parts such as medical devices, optical instruments,
wafers, PC boards, hybrid circuits, disk drive components, precision mechanical or
electromechanical components, or the like. In the precision cleaning industry in particular, there
20 exists a need for an efficient cleaning system generally having a high tank turnover rate.

Ultrasonic systems for processing and cleaning parts within a tank are generally known.
In a typical prior art ultrasonic system, the tank contains a cleaning solution and the parts to be
cleaned are introduced therein. Ultrasonic energy is applied to the tank, and the ultrasonic

vibrations generate pressure gradients within the cleaning solution, forming minute cavitation bubbles. These cavitations implode against a surface of the part to be cleaned releasing tremendous energy thereby dislodging contaminants.

5 In prior art systems, the ultrasonic energy is turned off while the solution within the tank is refreshed. For example, new or filtered solution is pumped into bottom of the tank, while the solution within the tank containing the contaminants overflows one or more sides out of the tank, to be filtered and reused or discarded. It is necessary to apply ultrasonic energy separately from refreshing the tank in these systems because the turbulence associated with a high rate of tank refreshing flow disrupts the ultrasonic wave pattern that produces the ultrasonic cavitations. In 10 prior art ultrasonic systems, mixing of contaminants within the tank with the refreshed solution still occurs such that the contaminants are eliminated slowly in a logarithmic manner over time. Logarithmic elimination of all contaminants theoretically takes an infinite amount of time, greatly reducing the overall turnover clean up rate.

One prior art ultrasonic system, described in U.S. Pat. No. 6,181,052, attempted to create 15 laminar flow within the tank by including at least two baffles at the bottom of the tank. The purpose of the baffles was to reduce the velocity of the incoming cleaning solution, equalize the pressure of the clean solution, and introduce the solution in the bottom of the tank with equal spatial distribution. However, these baffles as described have two serious shortcomings to achieve the desired results. First the upper baffle was welded into place within the tank, or 20 mounted within the tank such that the mounting bracket interferes with uniform flow up along the sidewalls of the tank, which introduces a counter-current within the tank causing turbulent mixing which again slows down the elimination of contaminants from the tank and the overall

Fig. 6 is a flow diagram of an embodiment of a recirculating ultrasonic cleaning system of the present invention.

Fig. 7 is a flow diagram of the cleaning tank used in the recirculating ultrasonic cleaning system of Fig. 6.

5

Detailed Description of the Invention

Figs. 1 and 2 illustrate a cleaning tank 100 of the present invention. Cleaning tank 100 typically has a welded construction using stainless steel. Alternatively, cleaning tank 100 can be constructed of other materials when the use of stainless steel is not recommended. Alternative
10 materials could include tantalum, titanium, quartz or plastics such as PEEK. As depicted, cleaning tank 100 has a rectangular cross-section though other geometrical configurations, such as cylindrical can be used without departing from the scope of the present invention.

As shown in Figs. 1 and 2, Cleaning tank 100 comprises an upper tank assembly 102, a lower tank assembly 104, a dispersion plate 106 and a pair of flange gaskets 108a, 108b. Flange
15 gaskets 108a, 108b are comprised of a suitable gasket material that is both chemically inert and non-leaching. For example, flange gaskets 108a, 108b can comprise polymers such as Teflon, PVDF, EPDM, Viton or perfluorinated elastomer. Upper tank assembly 102 includes a top lip 110 and an upper perimeter flange member 112. Lower tank assembly 104 includes a floor 116, an inlet port 118 and a bottom perimeter flange member 120. Floor 116 as shown in Fig. 3 can
20 further include an inlet plate 122 mounted above the inlet port 118. Upper perimeter flange member 112 and bottom perimeter flange member 120 are substantially identically shaped and sized.

Preferably, dispersion plate 106 comprises the same material of construction as cleaning tank 100, for example stainless steel. Dispersion plate 106 is constructed so as have essentially the same size and shape as defined by the upper perimeter flange member 112 and the bottom perimeter flange member 120. As illustrated in Fig. 4, dispersion plate 106 includes a plurality of spaced apart perforations 124. Perforations 124 are preferably uniform and can be formed by processes including laser cutting, mechanical punching, drilling or other suitable mechanical operations. In a preferred embodiment, perforations 124 are arranged in a close hex pattern 126 on the dispersion plate 106 as shown in Fig. 5. Perforations 124 are preferably circular but can be can be fabricated in other geometric configurations, for example squares, circles, ovals, rectangles or other suitable shapes. Perforations 124 are configured to have a perforation diameter 128 as small as possible for the specific cleaning application, for example, between 0.001 inches to 0.250 inches. When manufactured, a total perforation area 129 representing the sum of all the perforations 124 represents an amount slightly less than, equal to or greater than an inlet area 130 of the inlet port 118. In all embodiments, the total perforation area 129 represents less than 45% percent of the total area of the dispersion plate 106.

In assembling the cleaning tank 100, the dispersion plate 106 is placed over the bottom perimeter flange member 120 such that flange gasket 108a resides between them. Flange gasket 108b is placed on top of the dispersion plate 106. Finally, upper tank assembly 102 is positioned such that the upper perimeter flange member 112 resides on top of the flange gasket 108b. The lower tank assembly 102 and upper tank assembly 104 can then be operably coupled with a plurality of fasteners 132, for example nuts and bolts that project through aligned bores in the bottom perimeter flange member 120, the dispersion plate 106 and upper perimeter flange

member 112. Fasteners 132 can be exterior to or pass through the flange gaskets 108a, 108b. In an alternative embodiment, fasteners 132 can take the form of external clamps, for example c-clamps. By assembling the cleaning tank 100 in such a manner, it is possible to removably exchange alternative configurations of the dispersion plate 106, i.e dispersion plates 106 having
5 differing perforation 124 geometries, sizes and/or quantities. By varying the perforations 124, the dispersion plate 106 can be tailored for specific cleaning rates, part geometries and/or part loading arrangements.

Cleaning tank 100 can be used as part of a single-pass or recirculating ultrasonic cleaning system. A recirculating ultrasonic cleaning system 150 is shown schematically in Fig. 6.

10 Generally, the recirculating ultrasonic cleaning system 150 comprises the cleaning tank 100, a pump 152, an in-line filter 154 and a weir assembly 156. In a preferred embodiment, pump 152 has a pumping capacity providing for at least one tank volume per minute or more. Pump 152 preferably has an adjustable pump speed for varying flow rates based upon a variety of cleaning variables. In-line filter 154 comprises a commercially available in-line filter including a filter
15 media, for example polyether sulfone, Teflon, PVDF, polyester, or polypropylene, capable of removing particulates down to 0.03 microns in size. As shown in Fig. 7, cleaning tank 100 includes a plurality of exterior bonded, ultrasonic transducers 158. In a preferred embodiment, ultrasonic transducer 158 is a Crest Ultrasonic Corp. ceramic enhanced transducer supplying ultrasonic energy at a suitable frequency of between 28 KHz and 2.5 MHz. Ultrasonic
20 transducers 158 are bonded directly to the exterior of the upper tank assembly 102 with an adhesive such as epoxy. Recirculating ultrasonic cleaning system 150 can further comprise an inline heat exchanger 160. In addition, recirculating ultrasonic cleaning system 150 can include

a degasification unit 162 for removing dissolved gases, which can have adverse effects on the delivery of ultrasonic energy. While not depicted, it will be understood that recirculating ultrasonic cleaning system 150 can include suitable valve and or sensors for use during operation and draining.

5 To use recirculating ultrasonic cleaning system 150, a electronic, medical or optical part is placed within the cleaning tank 100, typically using a basket, a rack or a cleaning fixture, adapted for insertion into the cleaning tank 100. Prior to placing the loaded within the cleaning tank 100, the cleaning tank 100 is filled with a cleaning solution 166. Cleaning solution 166 can be suitable aqueous, semi-aqueous or solvent based solutions comprising any combination of
10 deionized water, detergents, or any number of suitable organic solvents alone or in mixtures. When cleaning solution 166 is an aqueous or semi-aqueous solution, inline heat exchanger 160 selectively heats or cools to maintains the temperature of the cleaning solution 166 in the recirculating loop between ambient and two hundred degrees F.

 Once cleaning tank 100 is filled with the cleaning solution 166 and the loaded basket, a
15 process logic controller (PLC) can be used to start the pump 152 to recirculate the cleaning solution 166 through the in-line filter 154 and into the cleaning tank 100 through the inlet port 118. The flow within the cleaning tank 100 is shown in Fig. 7. At inlet port 118, incoming cleaning solution 166 is distributed to the sides of cleaning tank 100 with inlet plate 122. The combination of inlet plate 122 and the backpressure applied by dispersion plate 106 results in a
20 turbulent flow pattern 168 within the lower tank assembly 104. The backpressure applied by dispersion plate 106 causes the cleaning solution 166 to distribute and flow upward evenly through the perforations 124 and into the upper tank assembly 102. The even flow of the

cleaning solution 166 through the perforation 124 results in a substantially parallel, laminar flow pattern 170 within the upper tank assembly 102. The laminar flow pattern 170 is maintained as cleaning solution 166 approaches the top lip 110 as there are no internal projections or obstructions along the sides of upper tank assembly 102 to disrupt the substantially parallel, upward flow of the cleaning solution 166.

As the cleaning solution 166 flows upward through the upper tank assembly 102, the ultrasonic transducer 158 supplies ultrasonic energy within the cleaning solution 166. The ultrasonic energy causes alternating patterns of low and high pressure phases within the cleaning solution 166. In the low pressure phase, bubbles or vacuum cavities are formed. In the high pressure phase, the bubbles implode violently. This process of creating and imploding bubbles is commonly referred to as cavitation. Cavitation results in an intense scrubbing process along the surface of the parts causing any particulate to be removed from the parts. The bubbles created during cavitation are minute and as such are able to penetrate microscopic crevices to provide enhanced cleaning as compared to simple immersion or agitation cleaning processes.

When particulates are removed from the part, the laminar flow pattern 170 carries the particulate upward and over the top lip 110. Once cleaning solution 166 overflows the upper tank assembly 102, the cleaning solution 166 and any removed particulate flows into the overflow weir 156. Overflow weir includes a drain whereby the cleaning solution 166 and any particulates are returned to an inlet side of the pump 152. Pump 152 circulates the cleaning solution 166 and particulates through the in-line filter 154 whereby the particulate is retained and the cleaning solution 166 is again directed into the cleaning tank 100 through the inlet port 118.

In a preferred embodiment, the recirculating ultrasonic cleaning system 150 is fully contained within a cabinet to present a pleasing, aesthetic appearance. In such a cabinetized system, a user need only supply the cleaning solution 166, a dispersion plate 106 including the desired perforation configuration, the parts and an electrical power source to power the
5 recirculating ultrasonic cleaning system 150.

It is understood that this invention is not intended to be unduly limited by the illustrative embodiments and examples set forth herein and that such examples and embodiments are presented by way of example only.